

# TP65H480G4JSGB

650V SuperGaN® GaN FET in PQFN (source tab)

# **Description**

The TP65H480G4JSGB 650V, 480m $\Omega$  Gallium Nitride (GaN) FET is a normally-off device using Renesas's Gen IV platform. It combines a state-of-the-art high voltage GaN HEMT with a low voltage silicon MOSFET to offer superior reliability and performance.

The Gen IV SuperGaN® platform uses advanced epi and patented design technologies to simplify manufacturability while improving efficiency over silicon via lower gate charge, output capacitance, crossover loss, and reverse recovery charge.

#### **Related Literature**

- Printed Circuit Board Layout and Probing
- Recommendations for Vapor Phase Reflow
- Recommended External Circuitry for GaN FETs
- PQFN Tape and Reel Information

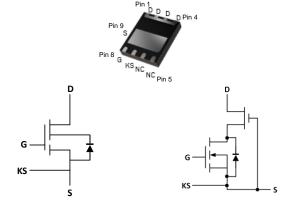
#### **Product Series and Ordering Information**

Part Number	Package	Package Configuration
TP65H480G4JSGB-TR*	5x6 PQFN	Source

<sup>\* &</sup>quot;-TR" suffix refers to tape and reel. Refer to AN0012 for details.

#### TP65H480G4JSGB PQFN

(bottom view)



**Cascode Schematic Symbol** 

**Cascode Device Structure** 

#### **Features**

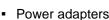
- Gen IV technology
- JEDEC-qualified GaN technology
- Dynamic R<sub>DS(on)eff</sub> production tested
- Robust design, defined by
  - Wide gate safety margin
  - Transient over-voltage capability
- Very low QRR
- Reduced crossover loss
- RoHS compliant and Halogen-free packaging

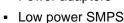
#### **Benefits**

- Achieves increased efficiency in both hard- and soft-switched circuits
  - Increased power density
  - Reduced system size and weight
  - Overall lower system cost
- Easy to drive with commonly-used gate drivers
- GSD pin layout improves high speed design

### **Applications**







Lighting







Key Specifications		
V <sub>DS</sub> (V)	650	
V <sub>DSS(TR)</sub> (V)	800	
R <sub>DS(on)</sub> (mΩ) max*	560	
Q <sub>RR</sub> (nC) typ	14	
Q <sub>G</sub> (nC) typ	5	

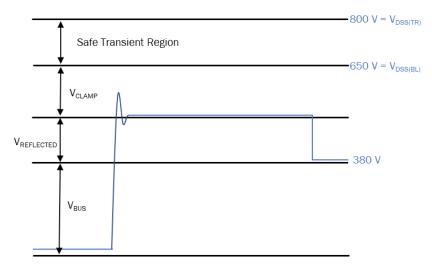
<sup>\*</sup> Dynamic R<sub>DS(on)</sub>; see Figures 18 and 19

# **Absolute Maximum Ratings** (T<sub>c</sub>=25 °C unless otherwise stated.)

Symbol	Parameter	Limit Value	Unit			
V <sub>DSS</sub>	Drain to source voltage (T <sub>J</sub> = -55°C	to 150°C)	650			
V <sub>DSS (TR)</sub>	Transient drain to source voltage (a)		800	V		
V <sub>GSS</sub>	Gate to source voltage		±10			
P <sub>D</sub>	Maximum power dissipation @Tc=2	5°C	13.2	W		
I_	Continuous drain current @Tc=25°C (b)		Continuous drain current @Tc=25°C (b)		3.6	А
I <sub>D</sub>	Continuous drain current @T <sub>C</sub> =100°C (b)		2.3	А		
I <sub>DM</sub>	Pulsed drain current (pulse width: 10µs)		16	А		
T <sub>C</sub>	Operating temperature	Case	-55 to +150	°C		
TJ	Operating temperature	Junction	-55 to +150	°C		
Ts	Storage temperature		-55 to +150	°C		
Tsold	Reflow soldering temperature (c)		260	°C		

#### Notes:

- a. In off-state, spike duration < 30 $\mu$ s, non-repetitive.
- b. For increased stability at high current operation, see Circuit Implementation on page 3
- c. Reflow MSL3



Primary Switch Voltage Stress (264 V AC)

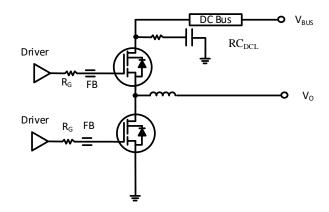
#### **Thermal Resistance**

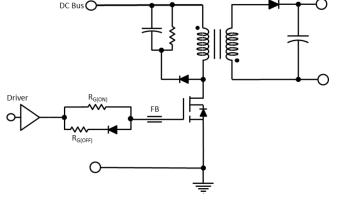
Symbol	Parameter	Typical	Unit
Rejc	Junction-to-case	9.5	°C/W
Roja	Junction-to-ambient (d)		°C/W

#### Notes:

d. Device on one layer epoxy PCB for source connection (vertical and without air stream cooling, with 6cm² copper area and 70µm thickness)

### **Circuit Implementation**





**Simplified Half-bridge Schematic** 

**Simplified Single Ended Schematic** 

Recommended gate drive: (0V, 6V) with R<sub>G(tot)</sub> = 65  $\Omega^{(e)}$ 

Recommended gate drive:

Gate drive: (0V, 6V): R<sub>G(ON)</sub>= 65 to 150  $\Omega$ ; R<sub>G(OFF)</sub>= 0 to 10  $\Omega$  Gate drive\*: (-6V, 6V): R<sub>G(ON)</sub>= 65 to 100  $\Omega$ ; R<sub>G(OFF)</sub>= 0 to 20  $\Omega$ 

\*Drop-in with discrete e-mode gate drive that level shifts any standard silicon MOSFET controller with integrated driver (i.e. NCP1342)

Gate Ferrite Bead (FB1)	Required DC Link RC Snubber (RC <sub>DCL</sub> ) <sup>(f)</sup>
240Ω @ 100MHz	4.7-10nF + 5Ω

#### Notes:

- e. For bridge topologies only.  $R_{\mbox{\tiny G}}$  could be much smaller in single ended topologies.
- f.  $RC_{\mbox{\tiny DCL}}$  should be placed as close as possible to the drain pin.

# **Electrical Parameters** (T<sub>2</sub>=25 °C unless otherwise stated)

Symbol	Parameter	Min	Тур	Max	Unit	Test Conditions	
Forward D	evice Characteristics	1	'	'	1		
V <sub>DSS(BL)</sub>	Maximum drain-source voltage	650	_	_	V	V <sub>GS</sub> =0V	
$V_{GS(th)}$	Gate threshold voltage	2	2.4	2.8	V	V <sub>DS</sub> =V <sub>GS</sub> , I <sub>D</sub> =0.5mA	
$\Delta V_{GS(th)}/T_J$	Gate threshold voltage temperature coefficient	_	-5.8	_	mV/°C		
		_	480	560		V <sub>GS</sub> =6V, I <sub>D</sub> =3A	
R <sub>DS(on)eff</sub>	Drain-source on-resistance (g)	_	1000	_	mΩ	V <sub>GS</sub> =6V, I <sub>D</sub> =3A, T <sub>J</sub> =150°C	
		_	1	10		V <sub>DS</sub> =650V, V <sub>GS</sub> =0V	
I <sub>DSS</sub>	Drain-to-source leakage current	_	5	_	μA	V <sub>DS</sub> =650V, V <sub>GS</sub> =0V, T <sub>J</sub> =150°C	
I <sub>GSS</sub>	Gate-to-source forward leakage current	_	_	100	nA.	V <sub>GS</sub> =10V	
1655	Gate-to-source reverse leakage current	_	_	-100		V <sub>GS</sub> =-10V	
Ciss	Input capacitance	_	414	_			
Coss	Output capacitance	_	7.93	_	pF	V <sub>GS</sub> =0V, V <sub>DS</sub> =400V, <i>f</i> =1MHz	
Crss	Reverse transfer capacitance	_	1.2	_			
C <sub>O(er)</sub>	Output capacitance, energy related (h)	_	12	_	pF	V <sub>GS</sub> =0V, V <sub>DS</sub> =0V to 400V	
$C_{\text{O(tr)}}$	Output capacitance, time related (i)	_	29	_	·		
$\mathbf{Q}_{G}$	Total gate charge	_	5	_		V <sub>DS</sub> =400V, V <sub>GS</sub> =0V to 10V, I <sub>D</sub> =3A	
Q <sub>GS</sub>	Gate-source charge	_	1.5	_	nC		
Q <sub>GD</sub>	Gate-drain charge	_	0.8	_			
Qoss	Output charge	_	11.6	_	nC	V <sub>GS</sub> =0V, V <sub>DS</sub> =0V to 400V	
$t_{D(on)}$	Turn-on delay	_	20.2	_		$V_{DS}$ =400V, $V_{GS}$ =0V to 6V, $I_{D}$ =3A, RG=65 $\Omega$ , ZFB=240 $\Omega$ at 100MHz	
t <sub>R</sub>	Rise time	_	2.4	_			
t <sub>D(off)</sub>	Turn-off delay	_	31.2	<u> </u>	ns		
t <sub>F</sub>	Fall time	_	10.6	_		(See Figure 14)	

#### Notes:

g. Dynamic  $R_{\scriptscriptstyle DS(cn)}\!,100\%$  tested; see Figures 18 and 19 for conditions

h. Equivalent capacitance to give same stored energy from 0V to 400V

i. Equivalent capacitance to give same charging time from 0V to 400V  $\,$ 

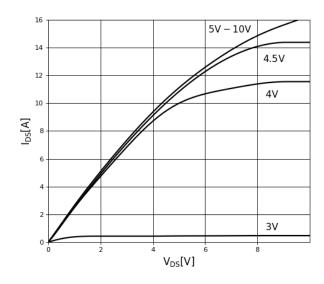
# **Electrical Parameters** (T<sub>2</sub>=25 °C unless otherwise stated)

Symbol	Parameter	Min	Тур	Max	Unit	Test Conditions
Reverse Device Characteristics						
ls	Reverse current	_	_	2.3	А	V <sub>GS</sub> =0V, T <sub>C</sub> =100°C, ≤25% duty cycle
$V_{SD}$	Reverse voltage (i)	_	1.3	_	V	V <sub>GS</sub> =0V, I <sub>S</sub> =1.15A
<b>V</b> SD	heverse voitage w	_	1.8	_		V <sub>GS</sub> =0V, I <sub>S</sub> =2.3A
t <sub>RR</sub>	Reverse recovery time	_	17.6	_	ns	I <sub>S</sub> =3.4A, V <sub>DD</sub> =400V,
Q <sub>RR</sub>	Reverse recovery charge	_	15.2	_	nC	di/dt=1000A/us

Notes:

j. Includes dynamic  $R_{\mbox{\tiny DS(on)}}$  effect

### **Typical Characteristics** (T<sub>c</sub>=25 °C unless otherwise stated)



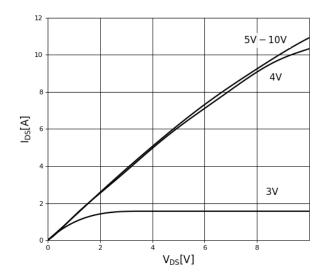


Figure 1. Typical Output Characteristics T<sub>J</sub>=25 °C

Parameter: V<sub>GS</sub>

Figure 2. Typical Output Characteristics T<sub>J</sub>=150 °C

Parameter: V<sub>GS</sub>

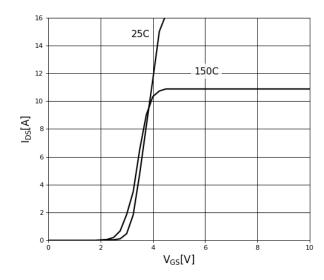


Figure 3. Typical Transfer Characteristics  $V_{DS}$ =10V, parameter:  $T_J$ 

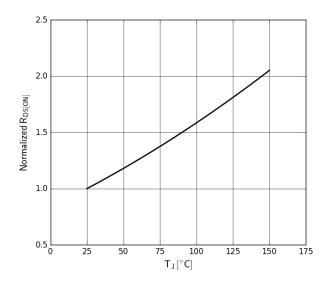
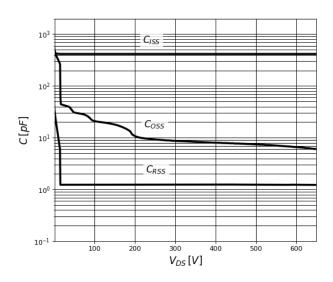


Figure 4. Normalized On-resistance  $I_D=3A,\ V_{GS}=6V$ 

# Typical Characteristics (T<sub>c</sub>=25 °C unless otherwise stated)



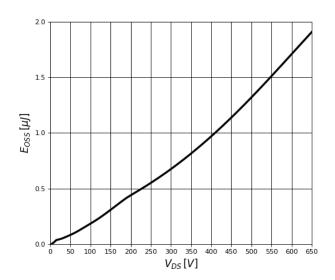
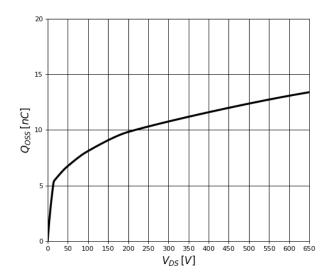


Figure 5. Typical Capacitance  $V_{GS}$ =0V, f=1MHz

Figure 6. Typical Coss Stored Energy



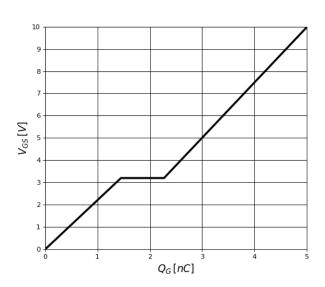
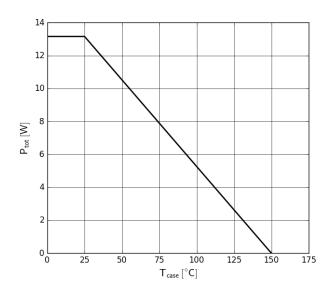


Figure 7. Typical Qoss

Figure 8. Typical Gate Charge

I<sub>DS</sub>=3A, V<sub>DS</sub>=400V

### **Typical Characteristics** (T<sub>c</sub>=25 °C unless otherwise stated)



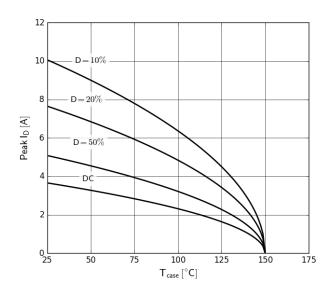
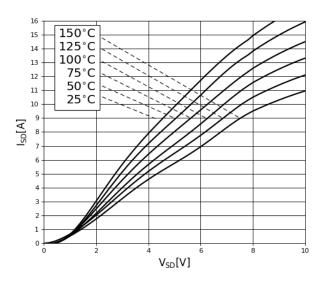


Figure 9. Power Dissipation

Figure 10. Current Derating

Pulse width  $\leq 10 \mu s$ ,  $V_{GS} \geq 10 V$ 



10°-1 10°-5 10°-4 10°-3 10°-2 10°-1 10°0 Time [s]

Figure 11. Forward Characteristics of Rev. Diode  $I_S=f(V_{SD})$ , parameter:  $T_J$ 

Figure 12. Transient Thermal Resistance

10<sup>1</sup>

# **Typical Characteristics** (T₀=25 °C unless otherwise stated)

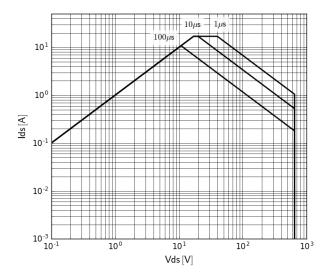


Figure 13. Safe Operating Area T<sub>C</sub>=25°C

# **Test Circuits and Waveforms**

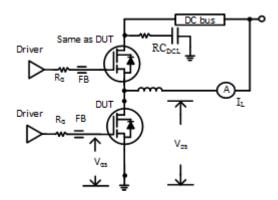


Figure 14. Switching Time Test Circuit

(see circuit implementation on page 3 for methods to ensure clean switching)

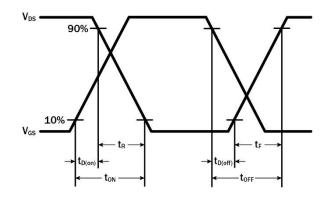


Figure 15. Switching Time Waveform

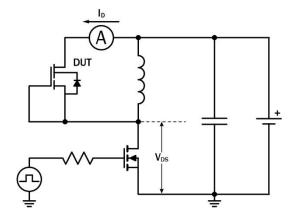


Figure 16. Diode Characteristics Test Circuit

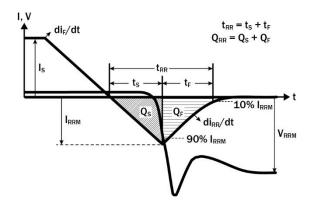


Figure 17. Diode Recovery Waveform

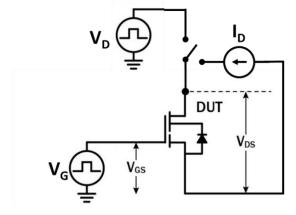


Figure 18. Dynamic R<sub>DS(on)eff</sub> Test Circuit

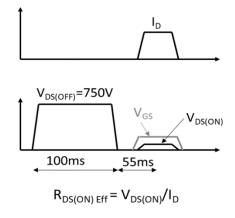


Figure 19. Dynamic R<sub>DS(on)eff</sub> Waveform

#### **Design Considerations**

The fast switching of GaN devices reduces current-voltage crossover losses and enables high frequency operation while simultaneously achieving high efficiency. However, taking full advantage of the fast switching characteristics of GaN switches requires adherence to specific PCB layout guidelines and probing techniques.

Before evaluating Renesas GaN devices, see application note Printed Circuit Board Layout and Probing for GaN Power Switches. The table below provides some practical rules that should be followed during the evaluation.

#### When Evaluating Renesas GaN Devices:

DO	DO NOT
Minimize circuit inductance by keeping traces short, both in the drive and power loop	Twist the pins of T0-220 or T0-247 to accommodate GDS board layout
Minimize lead length of TO-220 and TO-247 package when mounting to the PCB	Use long traces in drive circuit, long lead length of the devices
Use shortest sense loop for probing; attach the probe and its ground connection directly to the test points	Use differential mode probe or probe ground clip with long wire
See Printed Circuit Board Layout and Probing	

## **GaN Design Resources**

The complete technical library of GaN design tools can be found at Renesasusa.com/design:

- Evaluation kits
- Application notes
- Design guides
- Simulation models
- · Technical papers and presentations

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